IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of) Attorney Docket No.: SOEI0021
Ken SAWABE et al.) Confirmation No. 9014
Serial No.: 10/595,920) Group Art Unit: 1795
Filed: May 19, 2006) Examiner: Amanda C. WALKE
For: PHOTOSENSITIVE RESIN COMPOSITION, PHOTOSENSITIVE ELEMENT, RESIST PATTERN FORMING METHOD AND PROCESS FOR MANUFACTURING PRINTED CIRCUIT BOARD) Date: September 18, 2009)))

COMMENTS (G) ON STATEMENT OF REASONS FOR ALLOWANCE

MAIL STOP: ISSUE FEE

United States Patent and Trademark Office Customer Service Window Randolph Building 401 Dulany Street Alexandria, VA 22314

Sir:

In response to the Notice of Allowance mailed June 19, 2009, please enter the following comments regarding the application identified above as follows:

Remarks/Arguments begin on page 2 of this paper.

Appln. Serial No. 10/595,920 Attorney Docket No. SOEI0021

REMARKS

In response to the Notice of Allowance mailed June 19, 2009, Applicants make the

following Comments on Statement of Reasons for Allowance presented by the Examiner in

the Office Action of June 19, 2009, at 2, lines 2-14. The Examiner's Reasons for Allowance

deviates from the language of the allowed claims. Therefore, to the extent that the Examiner's

Reasons for Allowance mischaracterize the allowed claims 1, 4-8, 11, 13, 15, 16, 18-20, 23, 25

and 26, Applicants object. The claims, as written, speak for themselves. Applicants agree that

the claimed invention would not have been obvious at the time the invention was made, and

that no prima facie showing of anticipation or obviousness could be made in view of the prior

art of record.

Questions are welcomed by the below signed attorney for the Applicants.

Respectfully submitted,

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